Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	426353	(photoresist or polymer or resin) same metal	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 19:56
L4	34266	3 same mixture	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 19:57
L5	1092	4 same etch$3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 19:57
L6	31390788	5 and@pd<"1990331"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 19:58
L7	0	5 and @pd<"1990331"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 19:58
L8	0	5 and @pd<"1990331"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 19:58
L9	577	5 and @pd<"19990331"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 20:02
L10	1	9 and (simulat$3 same wafer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 20:03
L11	49	9 and "428"/$.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 20:15
L12	4	("4243696").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/07 20:15